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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Bruno GHYSELEN et al.

Confirmation No.: 8095

Application No.: 10/615,259

Group Art Unit: 2818

Filing Date: July 9, 2003

Examiner: Thao P. Le

For: PROCESS FOR TRANSFERRING A LAYER
OF STRAINED SEMICONDUCTOR
MATERIAL

Attorney Docket No.: 4717-7500

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

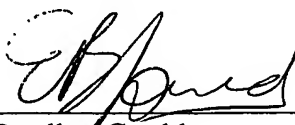
In response to the Restriction Requirement mailed June 24, 2004, Group II, which includes claims 1-35, is provisionally elected for prosecution in this application. Applicants expressly reserve the right to file one or more divisional or continuing applications to protect the inventions of the non-elected group and other disclosed, but unclaimed, subject matter prior to the issuance of this application.

No fee is believed to be due for this response. Should any fees be required, please charge such fees to Winston & Strawn LLP Deposit Account No. 50-1814.

Respectfully submitted,

July 22, 2004

Date



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